Electronic Acknowledgement Receipt					
EFS ID:	1433463				
Application Number:	10596178				
International Application Number:					
Confirmation Number:	3197				
Title of Invention:	Method for preparing nano-scale or amorphous particle using solid fat as a solvent				
First Named Inventor/Applicant Name:	Kab-Sig Kim				
Customer Number:	22442				
Filer:	Paul Sung Cha/carol werner				
Filer Authorized By:	Paul Sung Cha				
Attorney Docket Number:	5656BIO-1				
Receipt Date:	11-JAN-2007				
Filing Date:	02-JUN-2006				
Time Stamp:	17:08:11				
Application Type:	U.S. National Stage under 35 USC 371				
Payment information:					

Submitted with Payment	no
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## File Listing:

Document Number	Document Description	File Name	File Size(Bytes)	Multi Part /.zip	Pages (if appl.)
1	Power of Attorney	signed_BIOS_POA.pdf	75950	no	1
Warnings:					

Information:							
2	Power of Attorney	signed_Kim_POA.pdf	68239	no	1		
Warnings:		•					
Information	:						
	Total Files Size (in bytes): 144189						

This Acknowledgement Receipt evidences receipt on the noted date by the USPTO of the indicated documents, characterized by the applicant, and including page counts, where applicable. It serves as evidence of receipt similar to a Post Card, as described in MPEP 503.

## New Applications Under 35 U.S.C. 111

If a new application is being filed and the application includes the necessary components for a filing date (see 37 CFR 1.53(b)-(d) and MPEP 506), a Filing Receipt (37 CFR 1.54) will be issued in due course and the date shown on this Acknowledgement Receipt will establish the filing date of the application.

## National Stage of an International Application under 35 U.S.C. 371

If a timely submission to enter the national stage of an international application is compliant with the conditions of 35 U.S.C. 371 and other applicable requirements a Form PCT/DO/EO/903 indicating acceptance of the application as a national stage submission under 35 U.S.C. 371 will be issued in addition to the Filing Receipt, in due course.